

Spin-crossover Nanoparticles/MoS₂-based Hybrid Field-effect Transistor for Electronics

Josef Světlík<josef.svetlik@tul.cz>, Dr. Michal Řezanka, Dr. Marta Galbiati

This conference contribution presents molybdenum disulfide (MoS₂)-based field-effect transistor (FET) functionalized with spin-crossover (SCO) nanoparticles (NPs). Effect of SCO NPs on MoS₂ electronic properties by switching between two distinct states using an external stimulus is investigated.

Key words: two dimensional materials, molybdenum disulfide, spin-crossover nanoparticles, electronics.

Introduction

Classical devices employing Si are almost reaching their physical limits and alternatives, based on entirely new materials and principles, are being investigated and slowly penetrate from laboratory to industry. Examples of such new materials, which appear promising to be once used in the semiconducting industry, are two-dimensional materials (2DMs) and functional molecules due to their small dimensionality, low price, and unique functionalities. In both cases, materials display a full range of electrical, optical and magnetic properties, and therefore could find many distinct applications in a new generation of devices. Moreover, it appears advantageous to combine them, both, different 2DMs together [1], and 2DMs with functional molecules, in heterostructures, which gives rise to unusual physical phenomena. The fabrication of hybrid organic/inorganic devices is of great potential thanks to the possibility to synthesize desirable molecules with predictable functionalities, giving additional degrees of freedom to devices [2].

In this scenario, we integrate 2DM into FET and introduce functional molecules in the form of a thin layer of NPs to investigate its effect on electrical properties of the 2DM.

Theory

The research field of 2DMs has appeared relatively recently in 2004 when graphene was characterized for the first time. Graphene is a single layer of graphite that was obtained from its exfoliation using scotch tape. Despite the material has many appealing properties, there is one main limitation for the use of graphene resulting from its gapless band structure: it is not suitable to be used in transistors or optoelectronic

devices. This obstacle generated a search for alternative materials. Graphite indeed is not the only layered crystal, and many other mono-atomically thick materials with different chemical nature and various properties were prepared during the last years [3].

Among them, MoS₂ has become a prototypical 2DM thanks to its intriguing properties, such as mechanical flexibility, its ease of exfoliation with scotch tape, air stability even in monolayer mode, and semiconducting behaviour with tunable bandgap which have been greatly appreciated for the fabrication of FETs. Moreover, it has been theoretically predicted that by applying an elastic strain to MoS₂ it is possible to change its band structure from semiconducting to semimetallic. Thus, if we find a way how to reversibly apply strain to MoS₂, we could switch between these two electrical modes and use it in a new generation of devices.

One possible way to do that could be a functionalization of MoS₂ with SCO NPs. These NPs are synthesized from polymerizable SCO molecules, that can crossover from low to high spin state and vice versa as a result of an external stimulus (e.g. temperature, light). The SCO phenomenon is accompanied by a change of volume of the molecules and, as a result, NPs made of them expand and shrink their size about 10%. If present in a compact layer over MoS₂ surface, we could use them to apply reversible strain to the 2DM and effectively switch the electrical mode of the device (Figure 1).

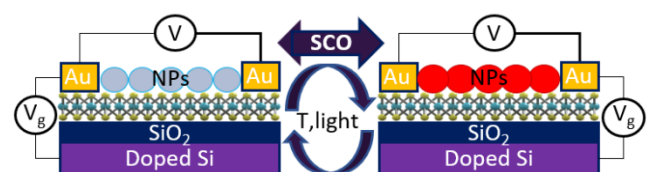


Figure 1: Hybrid NPs/MoS₂ switchable device. As the spin state of SCO NPs is switched by external stimulus, they change volume and are expected to apply strain to MoS₂.

Results and discussion

To prepare SCO NPs/MoS₂ hybrid FETs, first, thin layers of MoS₂ are exfoliated from MoS₂ crystal and deposited onto SiO₂/Si wafer. Then, the most suitable flakes for the device fabrication are found with an optical microscope and characterized with an atomic force microscope (AFM). We are looking for MoS₂ mono- and bi-layers with unbroken and clean surface with sufficient area to contact the flakes with electrodes (Figure 2). Only the thinnest flakes are selected since the strain effect of NPs is expected to influence mostly superficial layers of MoS₂, thus, if present, underneath layers could decrease signal of the investigated effect.

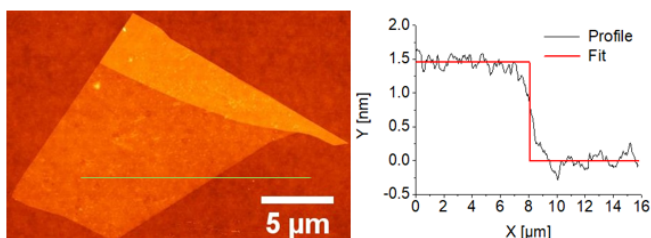


Figure 2: AFM image of selected MoS₂ flake and its profile. The green line represents section over which profile was measured.

The electrodes contacting selected flakes are formed by an e-beam lithography process and subsequent evaporation of Au in the ultra-high vacuum chamber. FET channel length (the gap between Au electrodes) is approximately 1.5 μm. Prepared devices are preliminarily electrically characterized to see their behaviour with changing light exposure and back gate.

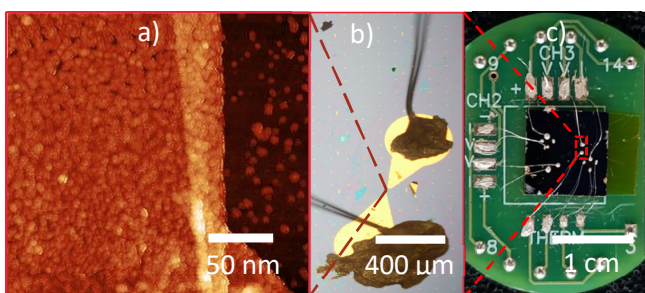


Figure 3: a) AFM image of MoS₂ flake after functionalization with SCO NPs; b) Optical microscopy image of Au electrodes contacting MoS₂ flake; c) Electrodes wired to the chip.

After that, functionalization of MoS₂ surface with SCO NPs is performed and devices are contacted to the chip to be measured at cryostat (Figure 3). First, IV curves at low temperature (280 K) and then at high temperature (400 K) are measured to see if the device works (Figure 4a). Then, temperature dependent measurements are performed with the step of 5 K/min. While heating up, we observe a change in slope of the

curve where SCO for NPs occurs [4] (Figure 4b). While cooling down, we do not observe a clear sign of transition probably due to a gradual change from high spin state to low spin state. However, the hysteresis loop is seen compare to the unfunctionalized device.

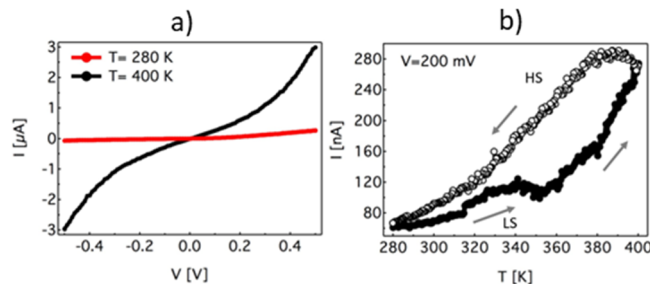


Figure 4: Electrical transport measurements of the SCO NPs/MoS₂ FET. a) IV curves at 2 distinct temperatures; b) Modulation of current with temperature.

Conclusion

SCO NPs/MoS₂-based hybrid FETs were fabricated, and electrical transport measurements were performed. Devices showed change in slope of the curve around the temperature where SCO NPs change their spin state.

Acknowledgement

This work was supported by the Student Grant Competition Project at the Technical University of Liberec in 2019. Further, I acknowledge funding from the EU (Advanced ERC grant SPINMOL and Erasmus+ grant). I would also like to express my gratitude to Prof. Eugenio Coronado's group and namely to Dr. Marta Galbiati. Finally, I would like to offer my thanks to Dr. Michal Řezanka.

References

- [1] Geim, A. K. & Grigorieva, I. V. Van der Waals heterostructures. *Nature* **499**, 419–425 (2013).
- [2] Forment-Aliaga, A. & Coronado, E. Hybrid Interfaces in Molecular Spintronics. *Chem. Rec.* **18**, 737–748 (2018).
- [3] Duong, D. L., Yun, S. J. & Lee, Y. H. van der Waals Layered Materials: Opportunities and Challenges. *ACS Nano* **11**, 11803–11830 (2017).
- [4] Giménez-Marqués, M., Larrea, M. L. G.-S. de & Coronado, E. Unravelling the chemical design of spin-crossover nanoparticles based on iron(II)-triazole coordination polymers: towards a control of the spin transition. *J. Mater. Chem. C* **3**, 7946–7953 (2015).